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**FORM PTO-1449** 

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

Sheet 1 of 1

ATTY. DOCKET NO. SERIAL NO.
026035-00008 10/768,151

APPLICANT
OTSUKI, et al.

FILING DATE GROUP

1751

February 2, 2004

## LIST OF REFERENCES CITED BY APPLICANT

(Use several sheets if necessary)

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JT	AA	3,484,293	12/16/1969	R.B. HODGDON, Jr.			
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	AE						
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JT	AM	Membranes for Fuel Cell Systems", March 10, 1998, Pgs. 47-66	ner Electrolyte
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	AO		

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/Jaison Thomas/

**DATE CONSIDERED** 

05/30/2006

\*EXAMINER:

Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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Sheet 2 of ATTY. DOCKET NO. SERIAL NO. U.S. DEPARTMENT OF COMMERCE **FORM PTO-1449** PATENT AND TRADEMARK OFFICE 026035-00008 10/768,151 **APPLICANT** LIST OF REFERENCES CITED BY APPLICANT OTSUKI, et al. (Use several sheets if necessary) FILING DATE GROUP 1751 February 2, 2004 **U.S. PATENT DOCUMENTS** EXAMINE PS SUB-**FILING** DOCUMENT CLASS CLASS DATE DATE NAME INITIALS NO. JT AΑ 5,221,482 6/22/1993 Yasushi MAEDA JT 4/18/2002 Jochen KERRES, et al. AB 2002/0045729 A1 JT AC 2003/0013817 A1 1/16/2003 Kelly LU AD ΑE ΑF FOREIGN PATENT DOCUMENTS TRANSLATION YES NO PART. SUB-**DOCUMENT** DATE COUNTRY **CLASS** CLASS NO. AG ΑH ΑI ΑK AL OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.) (C) Derwent; 1978-28042A; Teijin Ltd. JT AM ΑN AO

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